## **EXPEDITED PROCEDURE - EXAMINING GROUP 1775**

PATENT 1000

SAN 09/941,125

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appricant:

Gurtej Singh Sandhu et al.

Examiner: Arden B. Sperty

rial No.:

09/941,125

Group Art Unit: 1775

Filed:

August 28, 2001

Docket: 303.676US5

Title:

CHEMICAL VAPOR DEPOSITION OF TITANIUM

## AMENDMENT & RESPONSE UNDER 37 C.F.R. § 1.116

Box RCE Commissioner for Patents Washington, D.C. 20231

In response to the final Office Action mailed September 11, 2002, please amend the application as follows:

## IN THE DRAWINGS

The pending Office action stated that "The drawings are objected to under 37 CFR 1.83(a) because they fail to show the location of the titanium nitride layer and the fill as described in the specification. Any structural detail that is essential for a proper understanding of the disclosed invention should be shown in the drawing. MPEP § 608.02(d). A proposed drawing correction or corrected drawings are required in reply to the Office Action to avoid abandonment of the application. The objection to the drawings will not be held in abeyance."

Enclosed is a copy of Figure 3A of the drawings showing the following proposed amendment to Figure 3A in red ink. An optional layer of titanium nitride 40 and an optional fill 42 are now shown.

Applicant respectfully submits that no new matter is added in the attached amendment to the drawings. Among other locations, the amendments are supported on page 9, lines 15-17 of the specification. Reconsideration and withdrawal of the objection to the drawings is respectfully requested.